



Lecture on

Semiconductors / 半導体

(Physics of semiconductors)

2021.4.7 Lecture 01

Institute for Solid State Physics, University of Tokyo

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How the lecture will go on?

- Powerpoint (converted to pdf) file will be uploaded in the corresponding ITC-LMS site, (<https://itc-lms.ecc.u-tokyo.ac.jp/lms/course?idnumber=202135603-00290F01>) by the day before the lecture.
- The lecture notes (in Japanese, English) will be uploaded in the site <https://kats.issp.u-tokyo.ac.jp/kats/semicon4/> by the end of the lecture week.
- Small amount of problems for your exercise at home will be given in the last of the lecture in every two weeks. Submission deadline of the solutions is two weeks later. I hope I can collect them through LTC-LMS but if that is difficult I will prepare my own web script.
- In the very last of the lecture in July, the problems for your report will be given. The deadline for the submission of the report will be notified then.
- The lecture is recorded on the cloud. I hope I can upload the video for one or two weeks.
- I hope I can find some ways to get questions from you (via chat, etc.?)

Related site: <https://kats.issp.u-tokyo.ac.jp/kats/semicon4/>

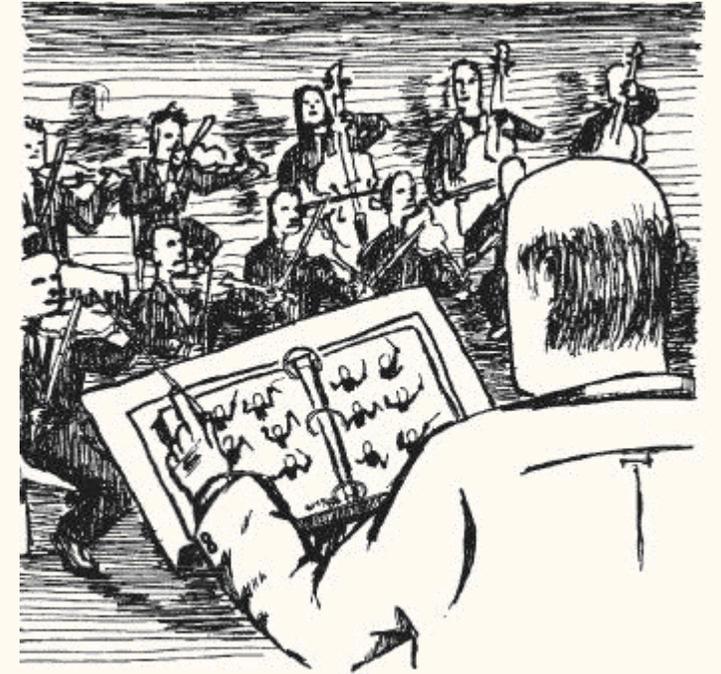
- | | |
|--|----------------------------------|
| 1) Crystal structure and crystal growth | 1) 結晶構造と結晶成長 |
| 2) Energy band, effective mass approximation | 2) エネルギーバンド, 有効質量モデル |
| 3) Carrier statistics and chemical doping | 3) 半導体キャリア統計とドーピング |
| 4) Optical properties | 4) 光学的性質 |
| 5) Semi-classical treatment of carrier transport | 5) 電気伝導の半古典論 |
| 6) Homo/hetero junctions, semiconductor devices (optical, electrical) | 6) ホモ・ヘテロ接合, 半導体デバイス (光, 電子) |
| 7) Quantum structures (quantum wells, wires, dots) by nanofabrication techniques | 7) 微細構造技術による量子構造 (量子井戸, 細線, ドット) |
| 8) Basics of quantum transport | 8) 量子輸送の基礎 |
| 9) Galvanomagnetic effects, Quantum Hall effects | 9) 電流磁気効果, 量子ホール効果 |
| 10) Spin-related phenomena (spintronics) | 10) スピン物性 (スピントロニクス) |
| 11) Topological effects | 11) トポロジカル効果 |

Characteristics of semiconductors

- Not metal
- Middle range band gap
- Weak divergence of resistivity with lowering temperature

Structure sensitive (conduction) properties

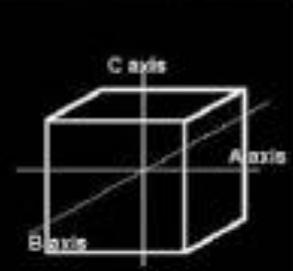
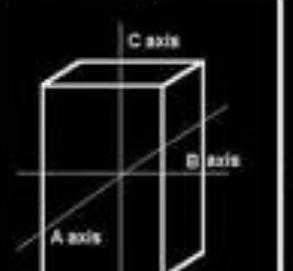
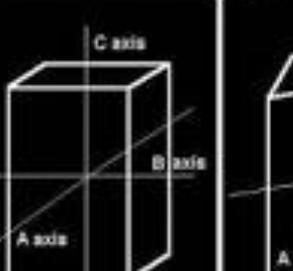
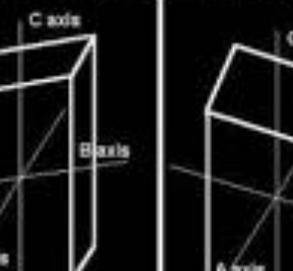
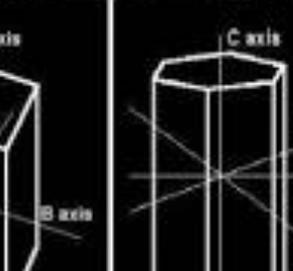
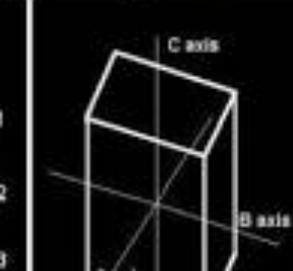
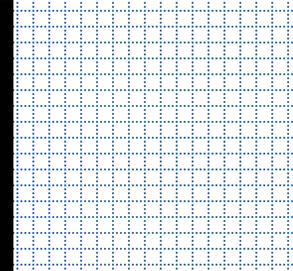
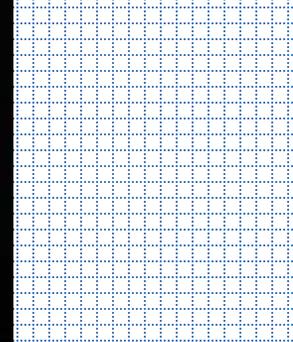
- Drastic changes in electric conduction with ultra-small amount of impurities
- Changes in electronic and optical properties with quantum confinement structures like quantum wells, wires, and dots



A SEMI-CONDUCTOR

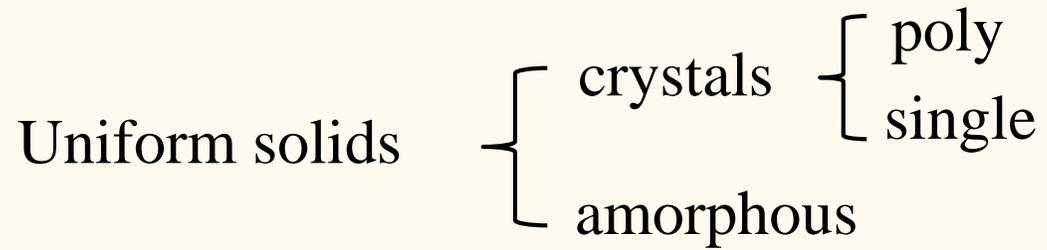
Yu & Cardona,
“Fundamentals of
Semiconductors”

Chapter 1 Crystal structures and crystal growths

| Crystal Systems | | | | | | |
|--|--|---|--|--|--|--|
| Isometric | Tetragonal | Orthorhombic | Monoclinic | Triclinic | Hexagonal | Trigonal |
|  |  |  |  |  |  |  |
|  |  |  |  |  |  |  |
| Fluorite | Wulfenite | Tanzanite | Azurite | Amazonite | Emerald | Rhodochrosite |

GeologyIn.com

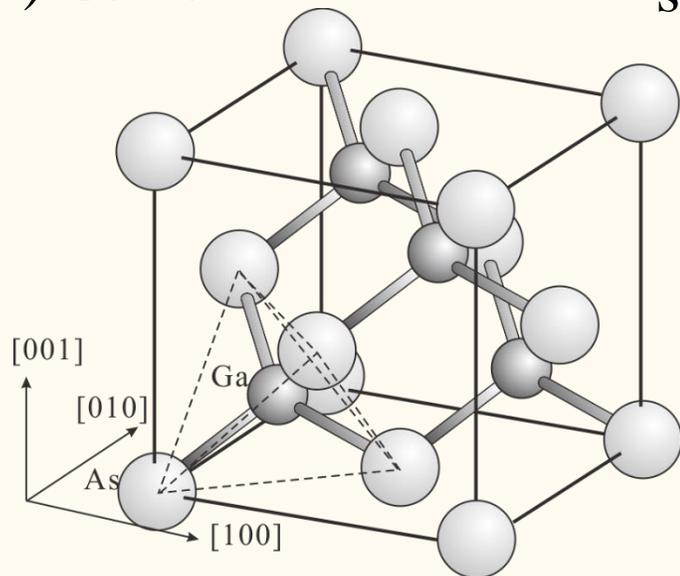
Crystal structure



Crystals: Spatially periodic structures

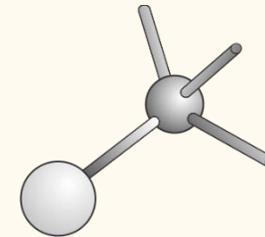
Unit of spatial repetition **Primitive cell**: unit of spatial repetition with smallest number of atoms

ex) GaAs **Unit cell**: unit of spatial repetition taken as for human to find symmetry of the crystal



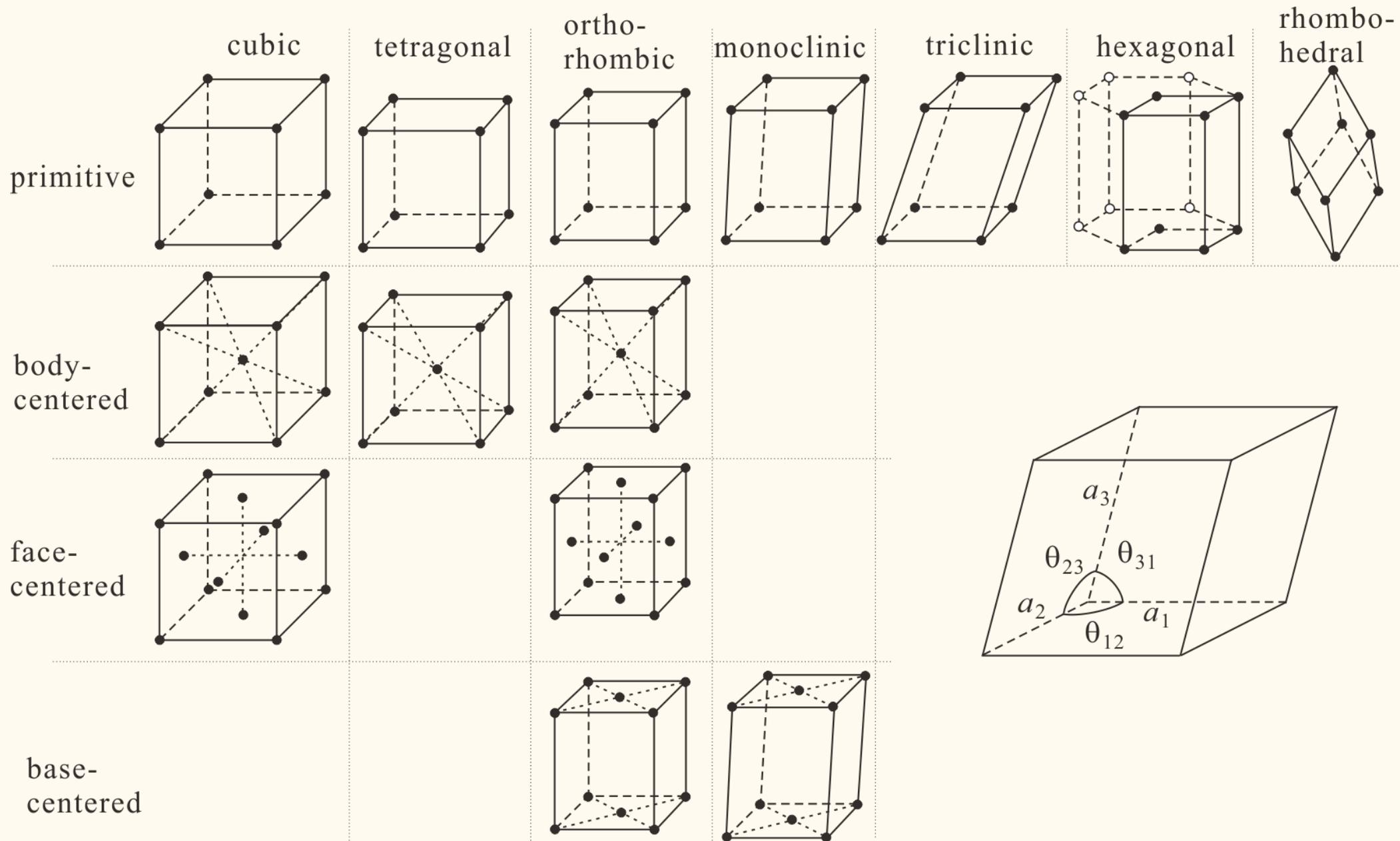
Unit cell

←
face centered cubic (fcc)



Primitive cell

Bravais lattices



Lattice, reciprocal lattice (1)

Lattice: spatial repetition of the unit structure.

$$\mathbf{r}' = \mathbf{r} + \sum_{i=1,2,3} l_i \mathbf{a}_i = \mathbf{r} + \mathbf{R}$$

l_i : integers, \mathbf{a}_i : primitive (translation) vector

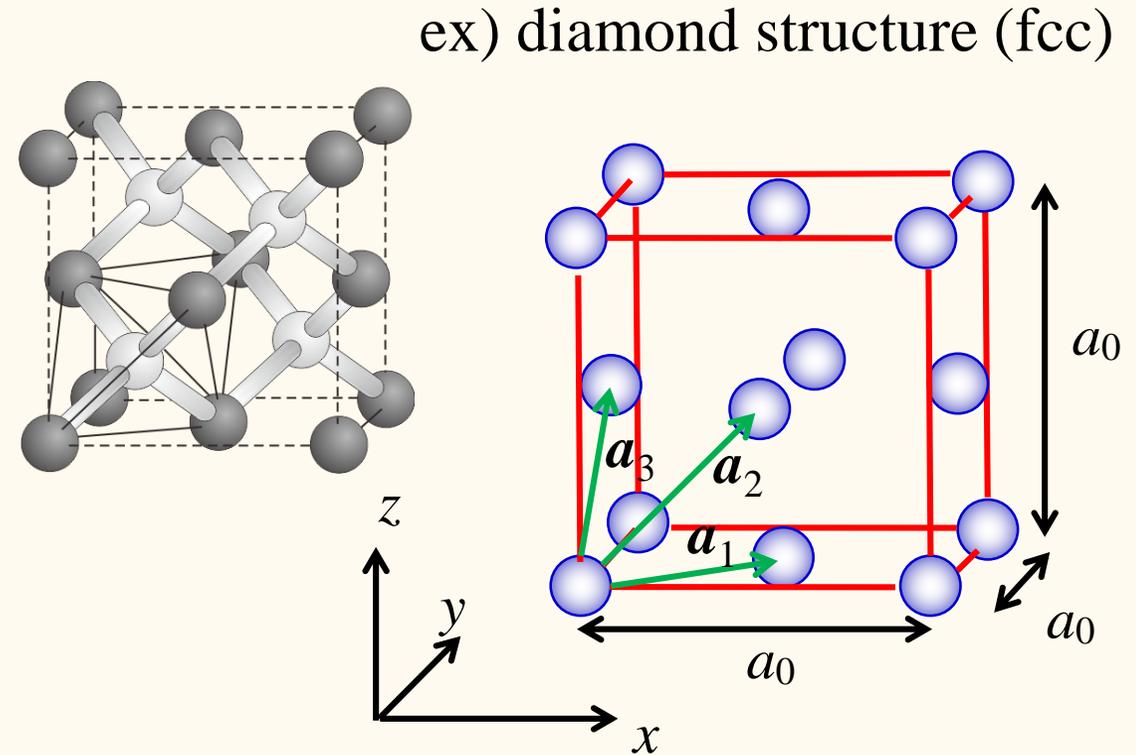
\mathbf{R} : lattice vector

Lattice potential $U(\mathbf{r})$
$$U(\mathbf{r}) = \sum_{\mathbf{G}} U_{\mathbf{G}} e^{i\mathbf{G}\cdot\mathbf{r}}$$

$$U(\mathbf{r} + \mathbf{R}) = U(\mathbf{r})$$

$$\mathbf{G} \cdot \mathbf{R} = 2\pi n \quad (n : \text{integer}), \quad \therefore e^{i\mathbf{G}\cdot\mathbf{R}} = 1$$

\mathbf{G} : reciprocal lattice vector



$$\mathbf{a}_1 = \frac{a_0}{2}(\mathbf{e}_x + \mathbf{e}_y), \quad \mathbf{a}_2 = \frac{a_0}{2}(\mathbf{e}_y + \mathbf{e}_z),$$
$$\mathbf{a}_3 = \frac{a_0}{2}(\mathbf{e}_z + \mathbf{e}_x)$$

Lattice, reciprocal lattice (2)

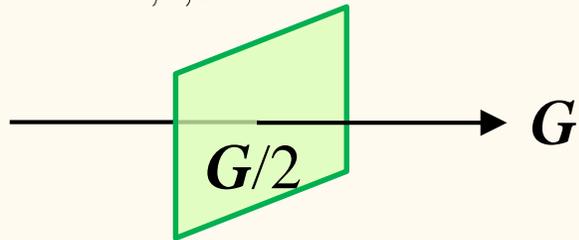
$$|A| \equiv \mathbf{a}_1 \cdot (\mathbf{a}_2 \times \mathbf{a}_3)$$

$$\mathbf{b}_1 = \frac{2\pi \mathbf{a}_2 \times \mathbf{a}_3}{|A|}, \quad \mathbf{b}_2 = \frac{2\pi \mathbf{a}_3 \times \mathbf{a}_1}{|A|},$$

$$\mathbf{b}_3 = \frac{2\pi \mathbf{a}_1 \times \mathbf{a}_2}{|A|}$$

primitive reciprocal vectors

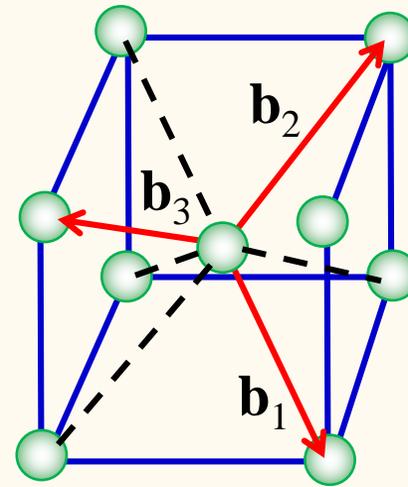
$$\mathbf{G} = \sum_{i=1,2,3} h_i \mathbf{b}_i, \quad (h_i: \text{integer})$$



Plane that cuts \mathbf{G} at $\mathbf{G}/2$ vertically

→ unit cell in the reciprocal lattice:

Brillouin zone

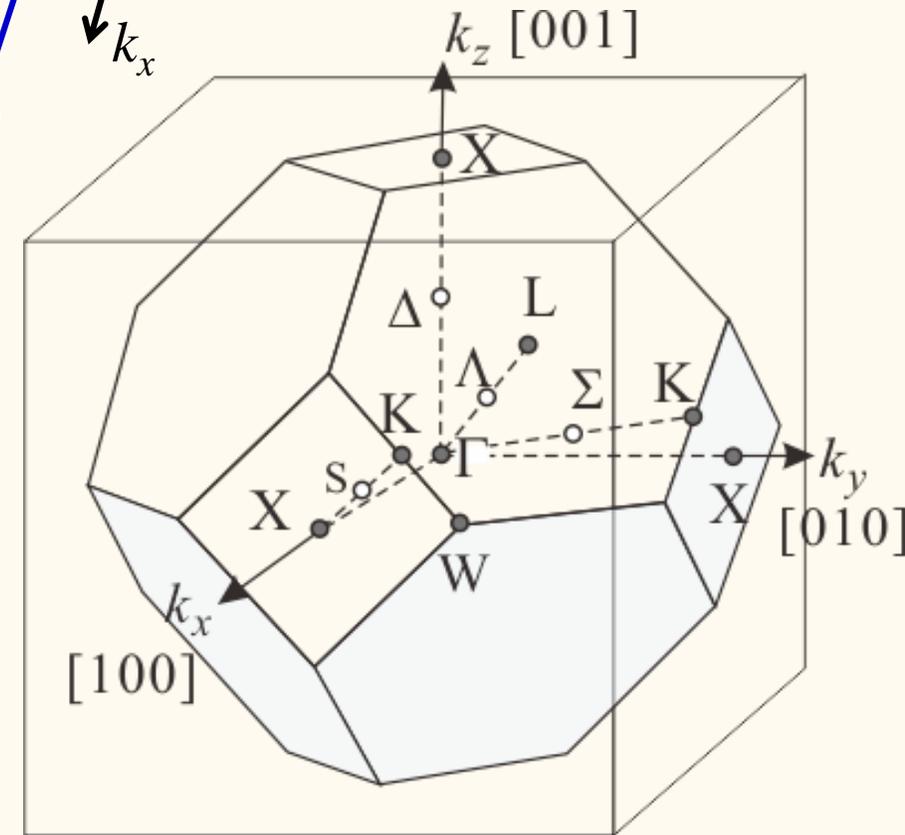


ex) diamond structure (fcc)
reciprocal lattice: bcc

First Brillouin zone

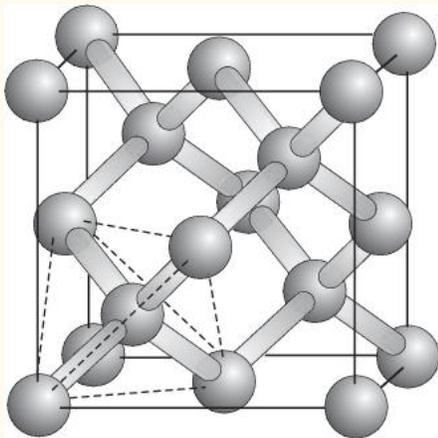
Points with high symmetries:

Γ, X, L, W



Inorganic crystals often used as semiconductors: Group IV

Diamond structure (fcc)



diamond



silicon



germanium



| II | III | IV | V | VI |
|-------------------------------------|--|------------------------------------|------------------------------------|---------------------------------|
| 4 Be ベリリウム 9.012182 | 5 B ホウ素 10.811 | 6 C 炭素 12.0107 | 7 N 窒素 14.0067 | 8 O 酸素 15.9994 |
| 12 Mg マグネシウム 24.305 | 13 Al アルミニウム 26.98153... | 14 Si ケイ素 28.0855 | 15 P リン 30.973762 | 16 S 硫黄 32.065 |
| 30 Zn 亜鉛 65.38 | 31 Ga ガリウム 69.723 | 32 Ge ゲルマニウム 72.63 | 33 As ヒ素 74.9216 | 34 Se セレン 78.96 |
| 48 Cd カドミウム 112.411 | 49 In インジウム 114.818 | 50 Sn スズ 118.71 | 51 Sb アンチモン 121.76 | 52 Te テルル 127.6 |

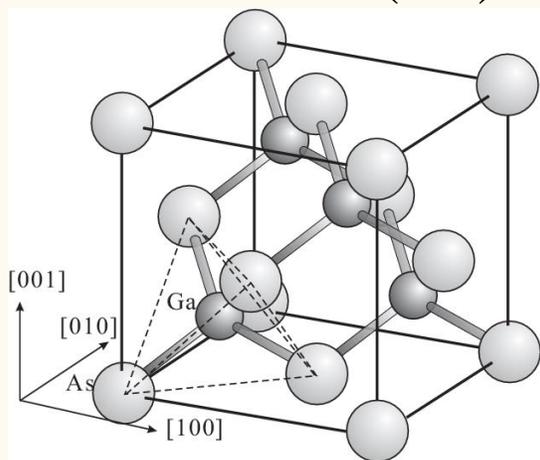
(α -Sn)

SiC

Si_xGe_{1-x}

Inorganic crystals often used as semiconductors: Group III-V

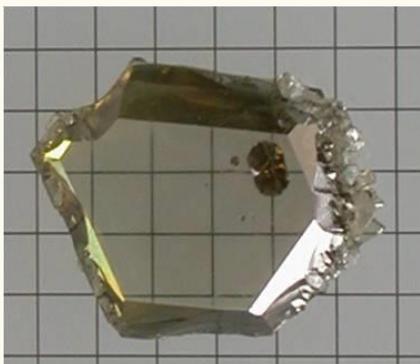
Zinc-blende (fcc)



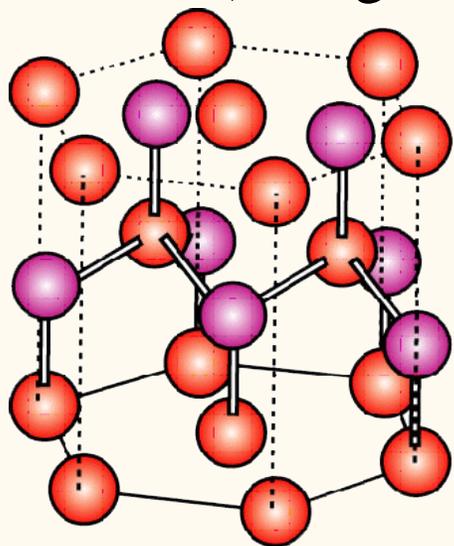
GaAs
(ZB)



GaN
(WZ)



Wurzeit (hexagonal)



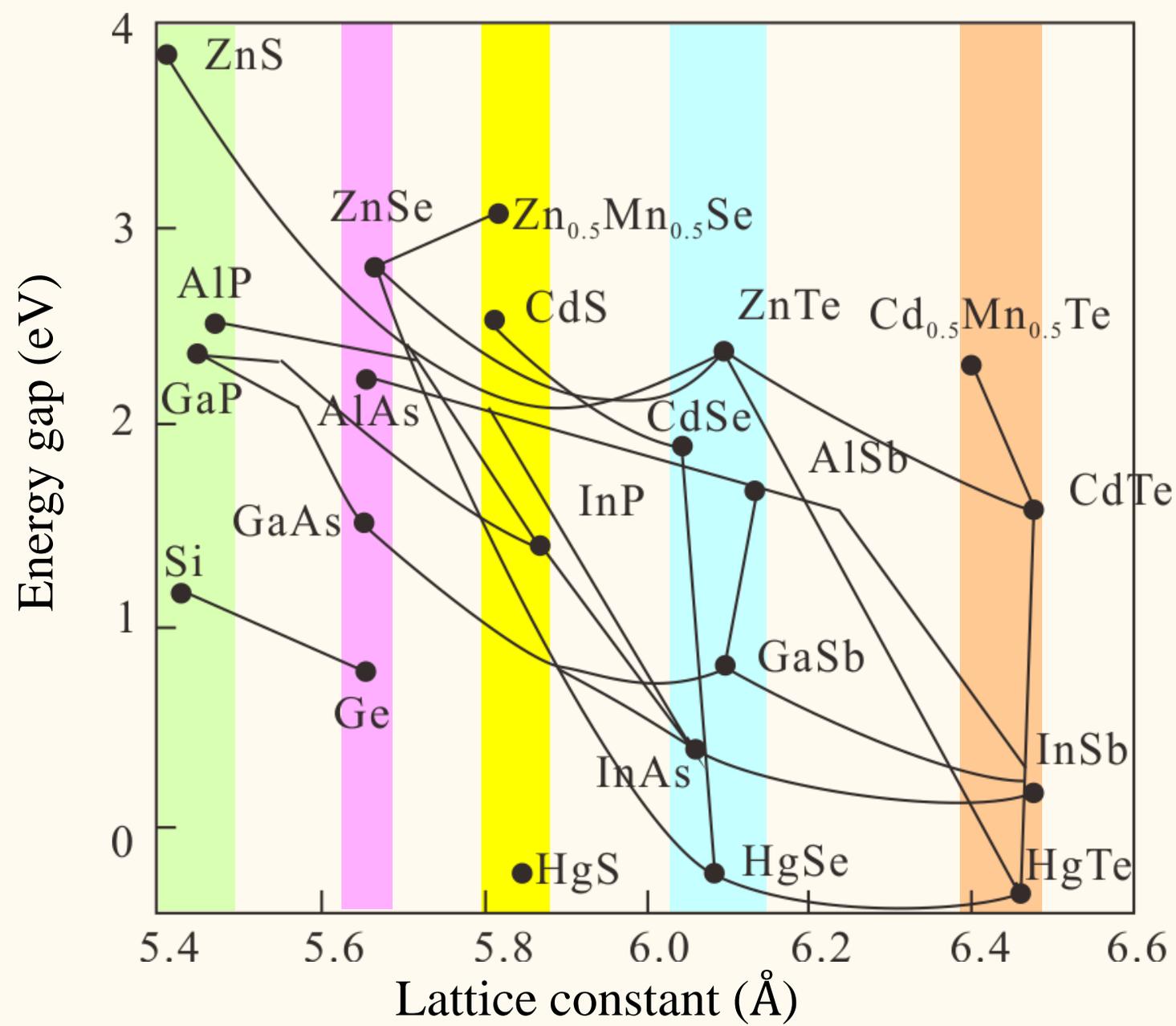
CdTe
(ZB)



| II | III | IV | V | VI |
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Energy gaps and lattice constants of representative (cubic) semiconductors



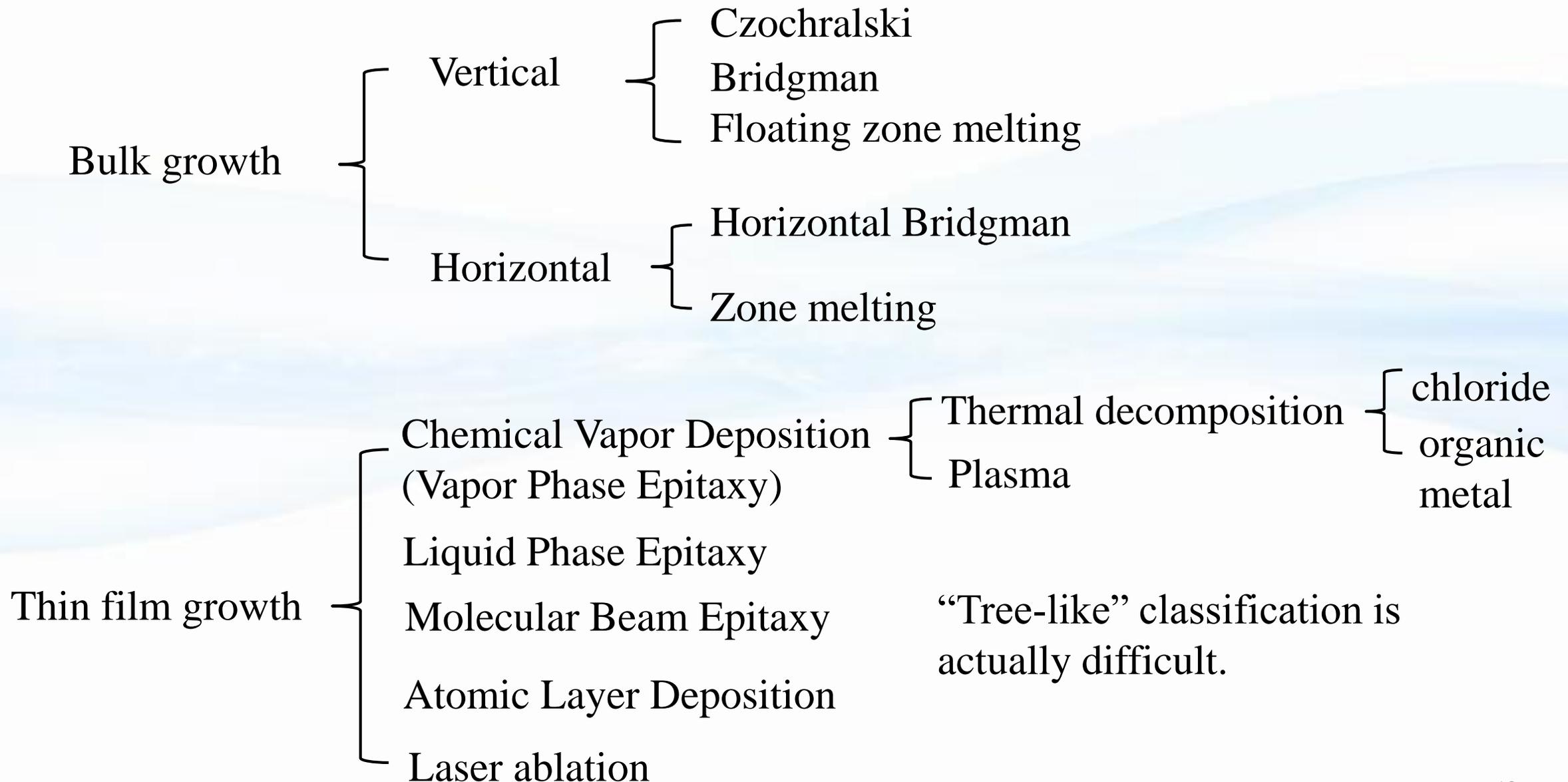
Room temperature

Colored stripes:
Lattice matching groups
→ Heterojunctions are available

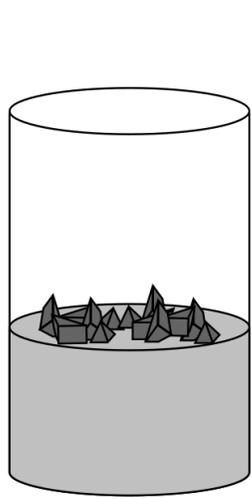
Lines: Mixed crystals

GaN (Wurzeit)
 $a = 3.19 \text{ \AA}$, $c = 5.19 \text{ \AA}$
3.4 eV (RT)

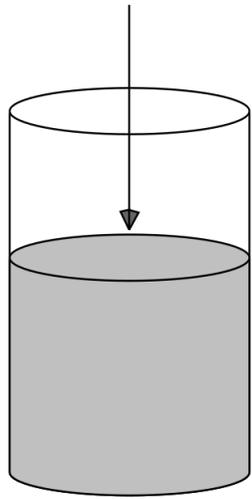
Various methods for semiconductor crystal growth



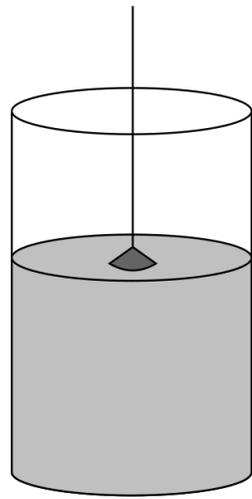
Crystal growth: Czochralski method



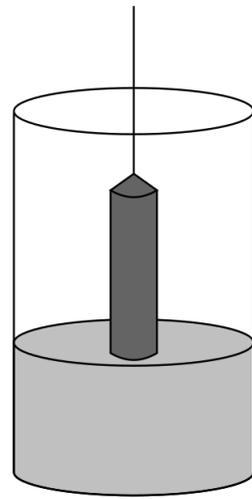
Melting of polysilicon, doping



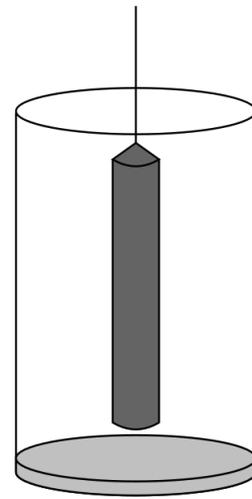
Introduction of the seed crystal



Beginning of the crystal growth



Crystal pulling

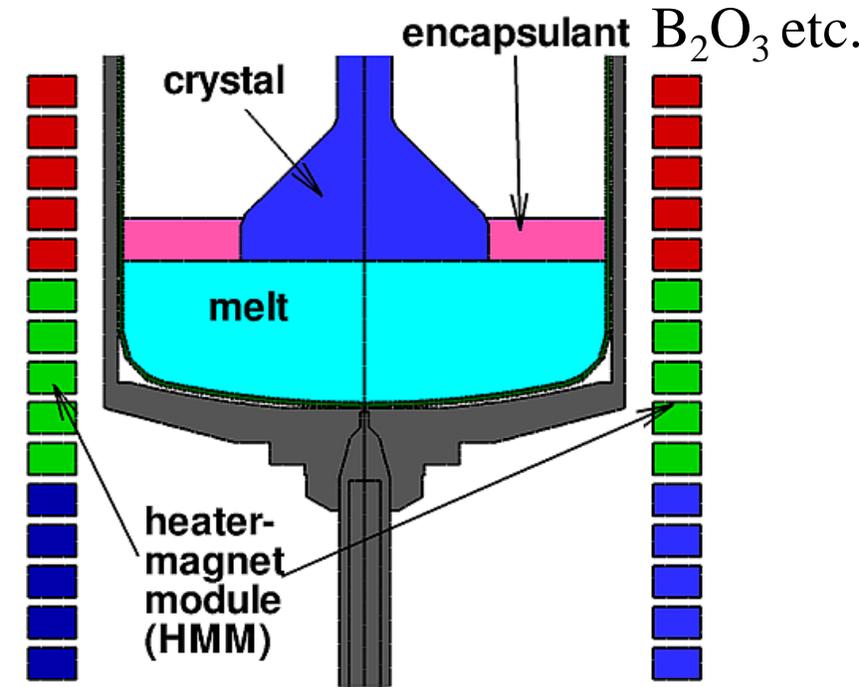


Formed crystal with a residue of melted silicon



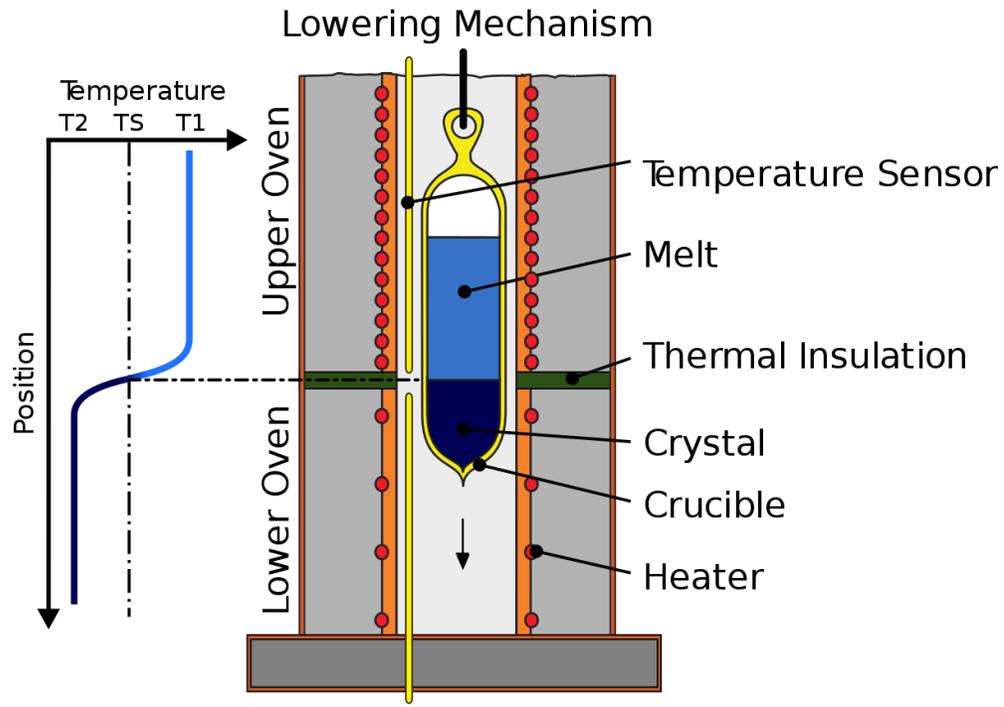
Czochralski method for silicon (Wikipedia)

Liquid encapsulated Czochralski (LEC) (GaAs, InP, etc. high vapor pressure materials)



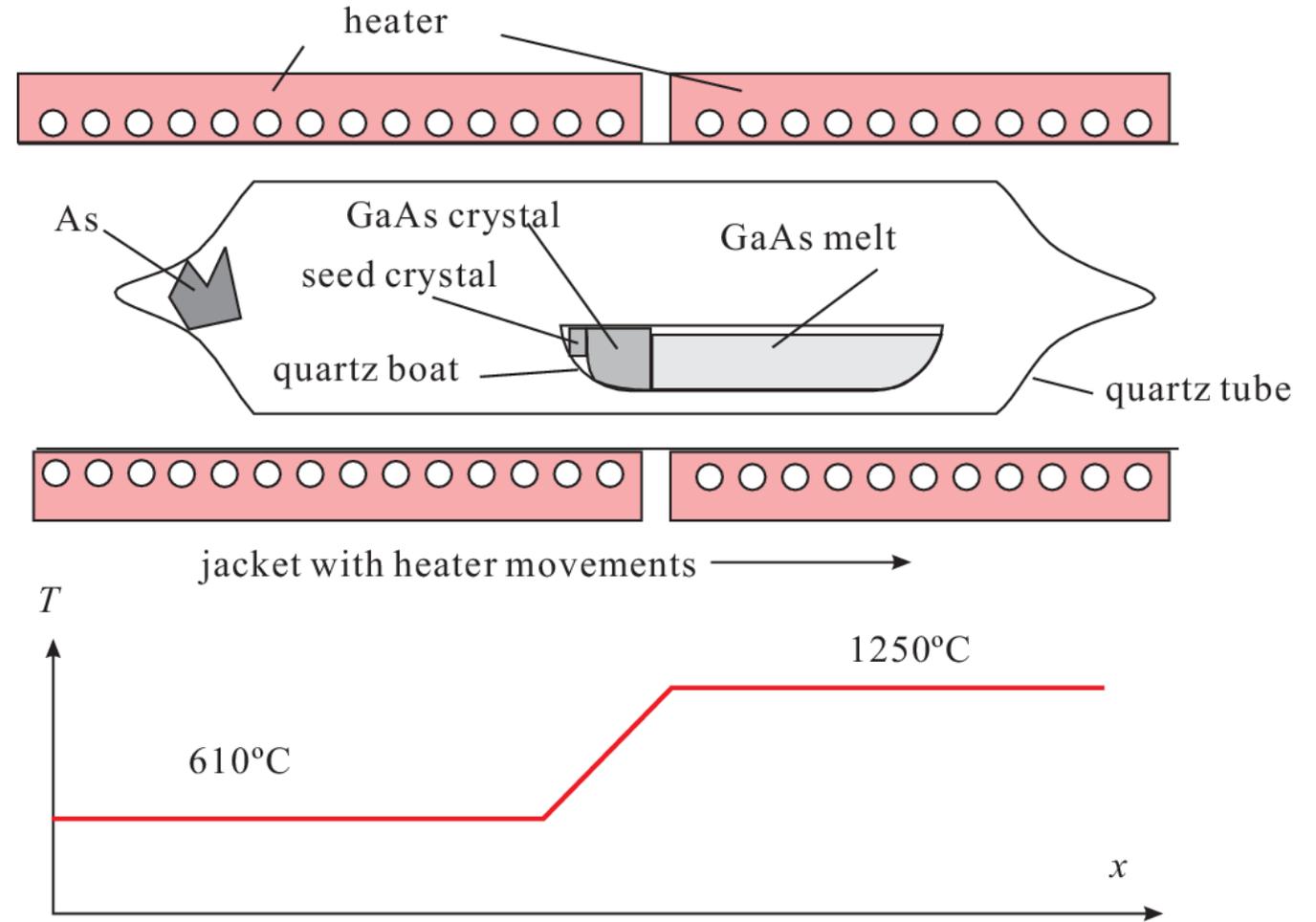
Bridgman methods

Bridgman-Stockbarger method



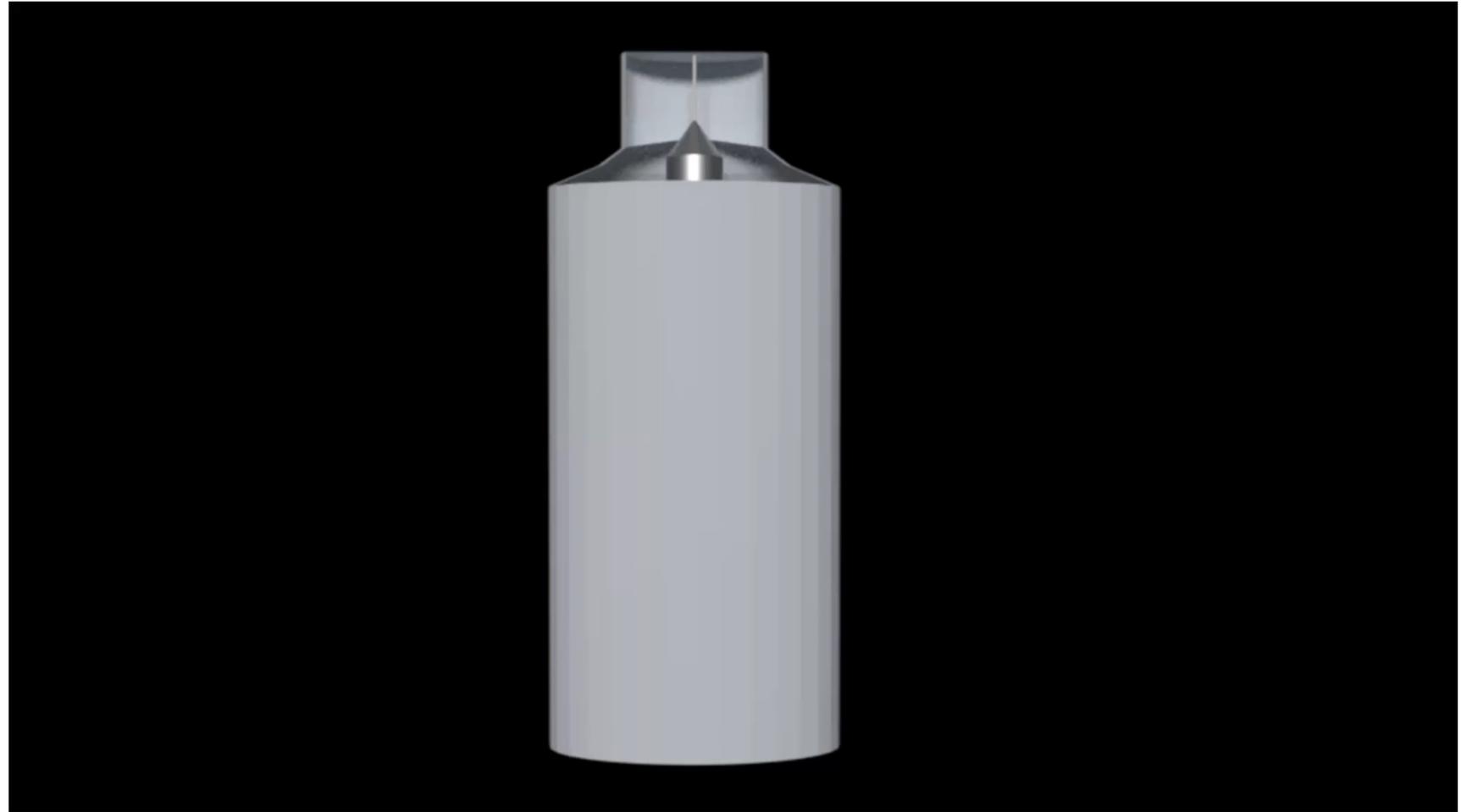
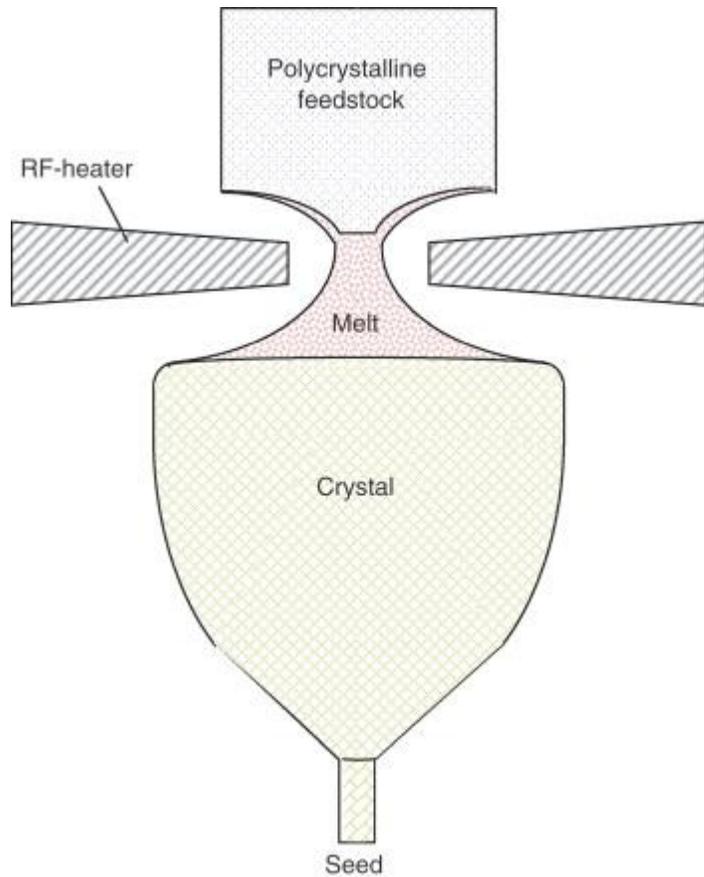
From Wikipedia

Horizontal Bridgeman (HB) process



temperature gradient freezing method

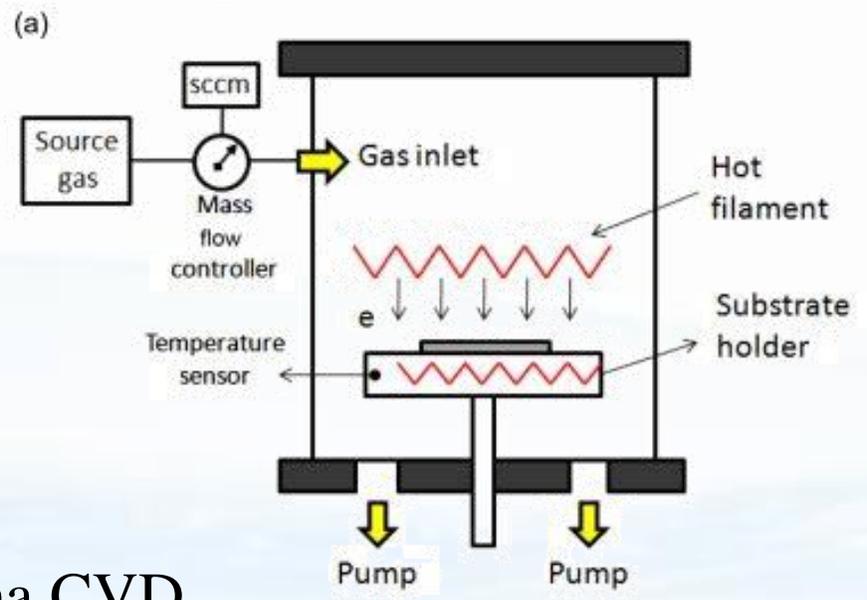
Floating zone method



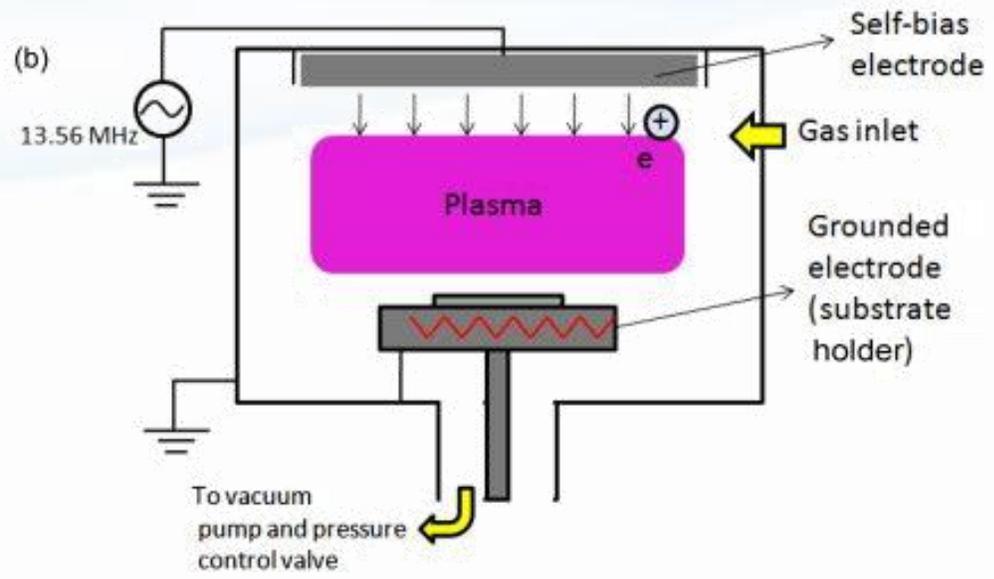
<https://www.youtube.com/watch?v=jPijg8NIamo>

Chemical vapor deposition (CVD), metal-organic CVD (MOCVD)

Thermal decomposition

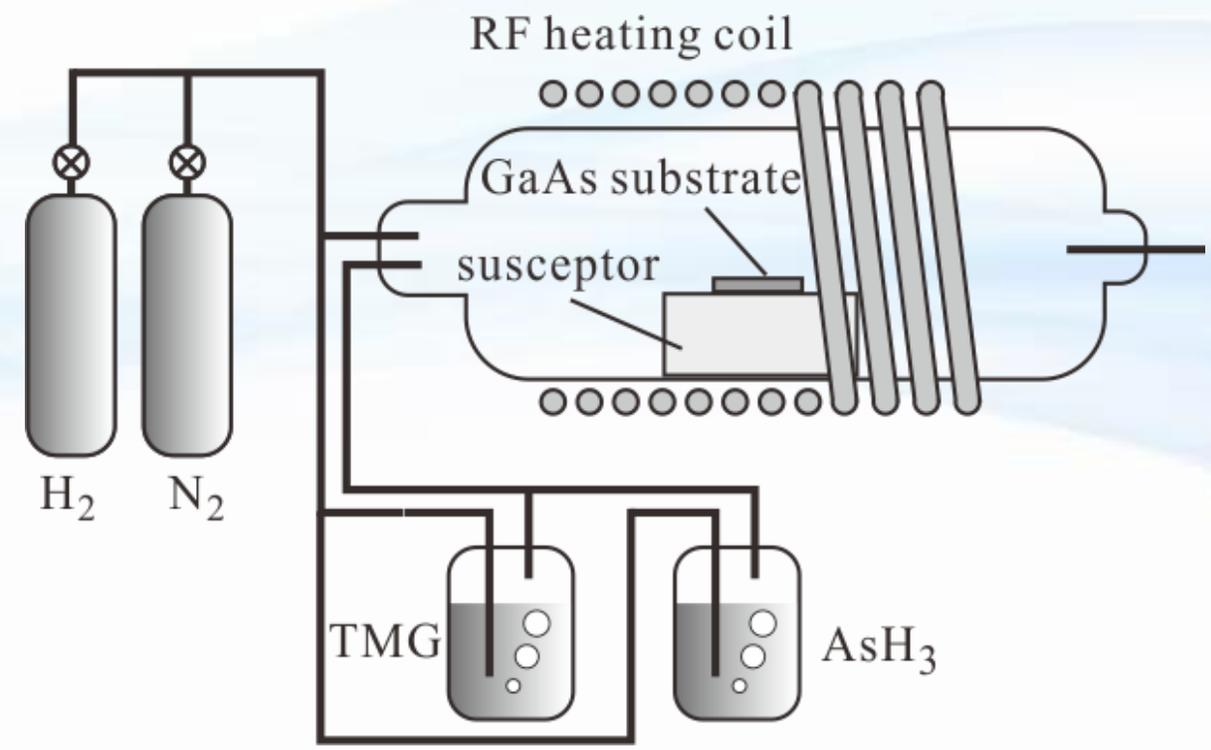


Plasma CVD



MOCVD

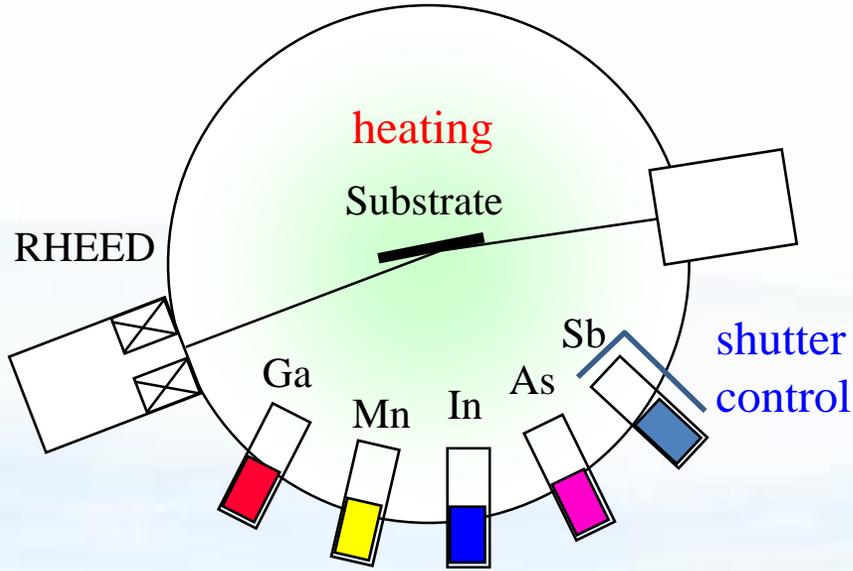
(organometallic vapor phase epitaxy, OMVPE)



Organic metal gases

Molecular Beam Epitaxy (MBE)

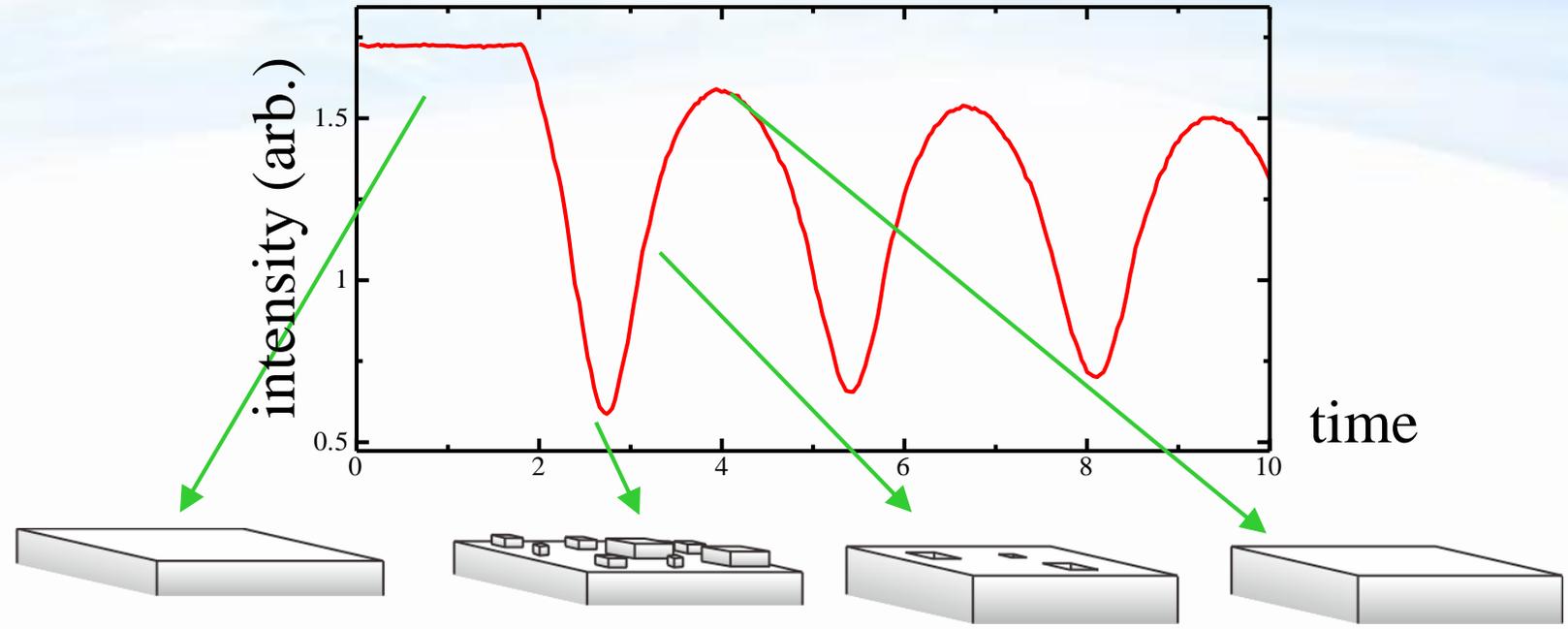
Ultra-high vacuum evaporation



Refractive high energy electron diffraction (RHEED)



HRTEM



Chapter 2 Energy bands, effective mass approximation



Bing Concert hall at Stanford University

<https://www.deccaurope.com/Case-Studies/bing-concert-hall-at-stanford-university-california>

Bloch theorem and nearly free electron model

Bloch theorem

Eigenstates in lattice potential:

$$\psi_{n\mathbf{k}}(\mathbf{r}) = u_{n\mathbf{k}}(\mathbf{r}) \exp(i\mathbf{k} \cdot \mathbf{r})$$

$$u_{n\mathbf{k}}(\mathbf{r} + \mathbf{R}) = u_{n\mathbf{k}}(\mathbf{r}) \quad \mathbf{R}: \text{Lattice translation vector}$$

n : band index

One-dimensional system with a weak periodic potential

$$V(x) = 2V_0 \cos(k_w x) \quad (k_w = 2\pi/a, \quad a: \text{lattice const.})$$

$$\langle k' | V | k \rangle = V_0 \langle k' | (e^{ik_w x} + e^{-ik_w x}) | k \rangle = V_0 (\delta_{k'k+k_w} + \delta_{k'k-k_w}) \quad \text{Perturbation is important from } k \pm k_w$$

Energy crossing between $|k\rangle$ and $|k - k_w\rangle$ occurs around $k = k_w/2$

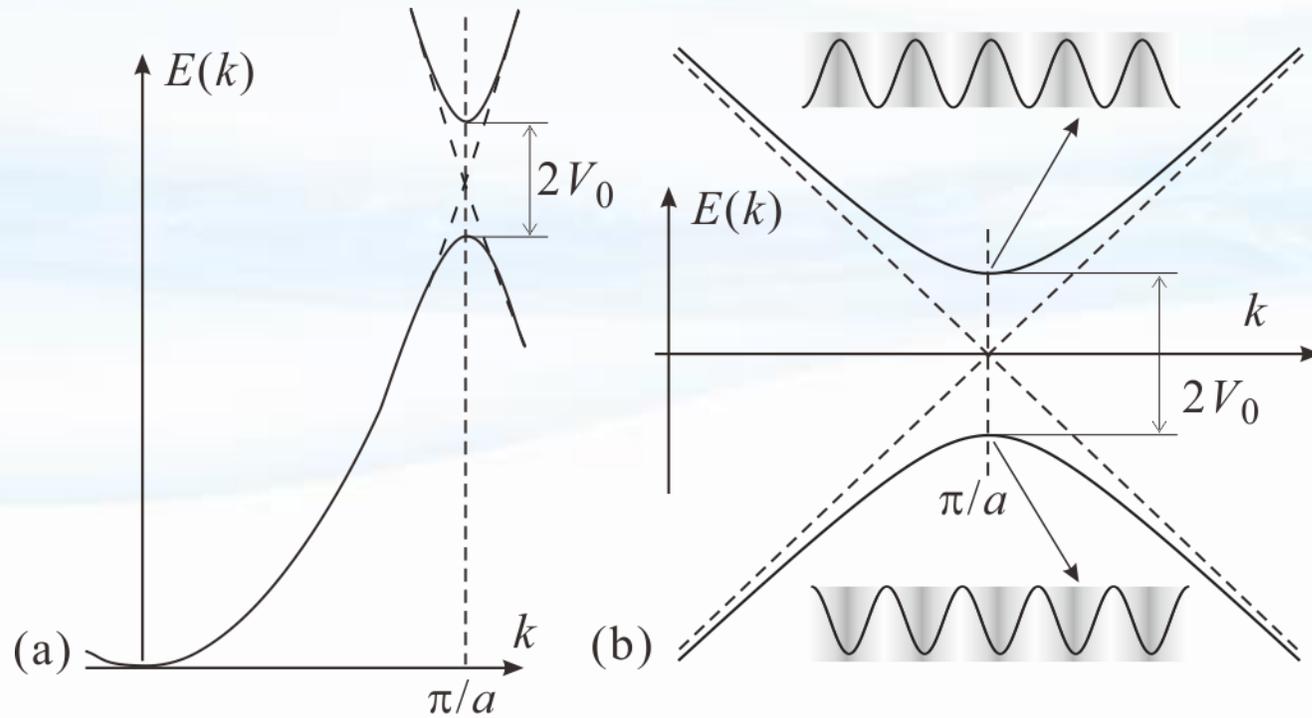
Hamiltonian around $k = k_w/2$ in the space formed with $|k\rangle$ and $|k - k_w\rangle$

$$\mathcal{H} = \begin{bmatrix} \frac{\hbar^2 k^2}{2m_0} & V_0 \\ V_0 & \frac{\hbar^2 (k - k_w)^2}{2m_0} \end{bmatrix} \approx \begin{bmatrix} \epsilon_z - \frac{\hbar^2 k_w \Delta k}{2m_0} & V_0 \\ V_0 & \epsilon_z + \frac{\hbar^2 k_w \Delta k}{2m_0} \end{bmatrix} \quad k = k_w/2 - \Delta k$$

Nearly free electron model (2)

$$E_{\pm} = \epsilon_z \pm \sqrt{\epsilon_z \frac{\hbar^2 (\Delta k)^2}{2m_0} + V_0^2} \quad \epsilon_z = \frac{\hbar^2 k_w^2}{8m_0}$$

Energy gap: $\Delta k = 0 \rightarrow 2V_0$



Overall dispersion

Energy gap due to the phases of standing waves

Bloch theorem

$$\psi_{n\mathbf{k}}(\mathbf{r}) = u_{n\mathbf{k}}(\mathbf{r}) \exp(i\mathbf{k} \cdot \mathbf{r})$$

Standing wave

$$\begin{aligned} e^{ik_w x/2} \pm e^{-ik_w x/2} &= (1 \pm e^{-k_w x}) e^{ik_w x/2} \\ &= \underline{(e^{k_w x} \pm 1)} e^{-ik_w x/2} \end{aligned}$$

Lattice periodic function

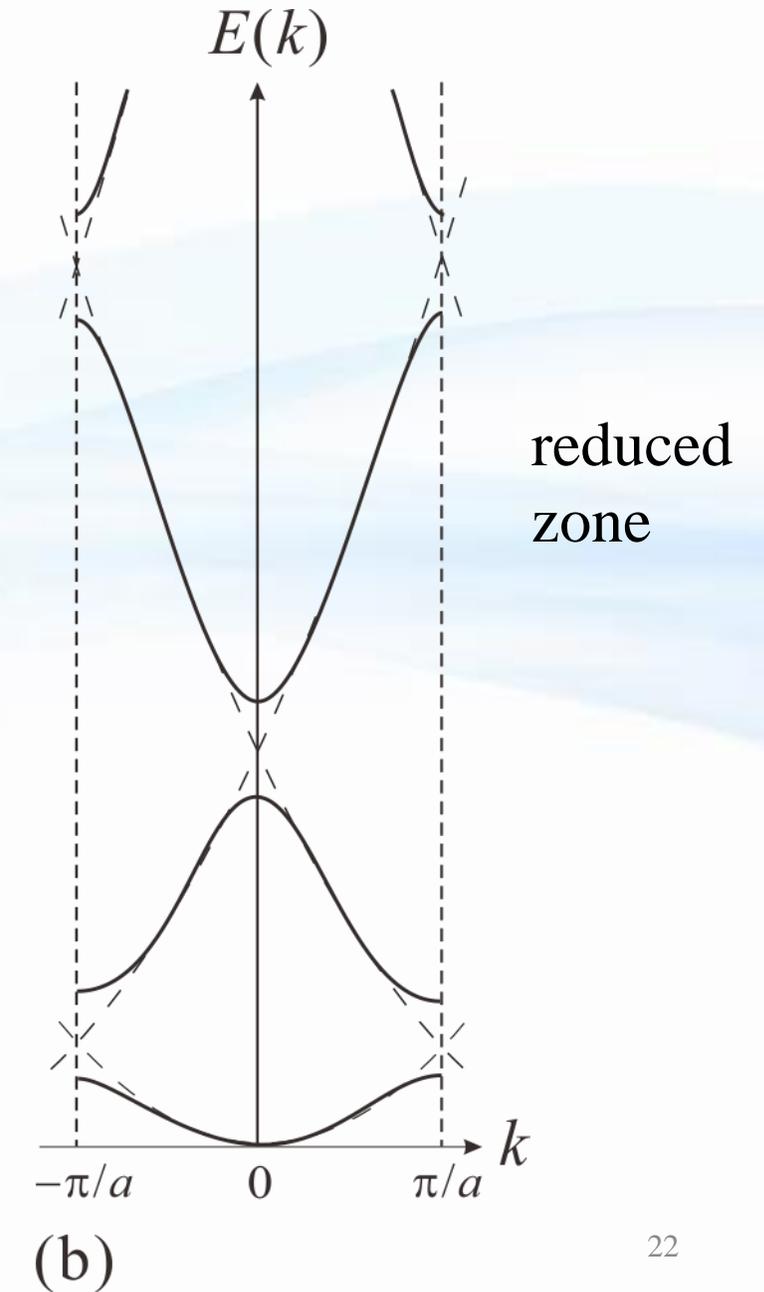
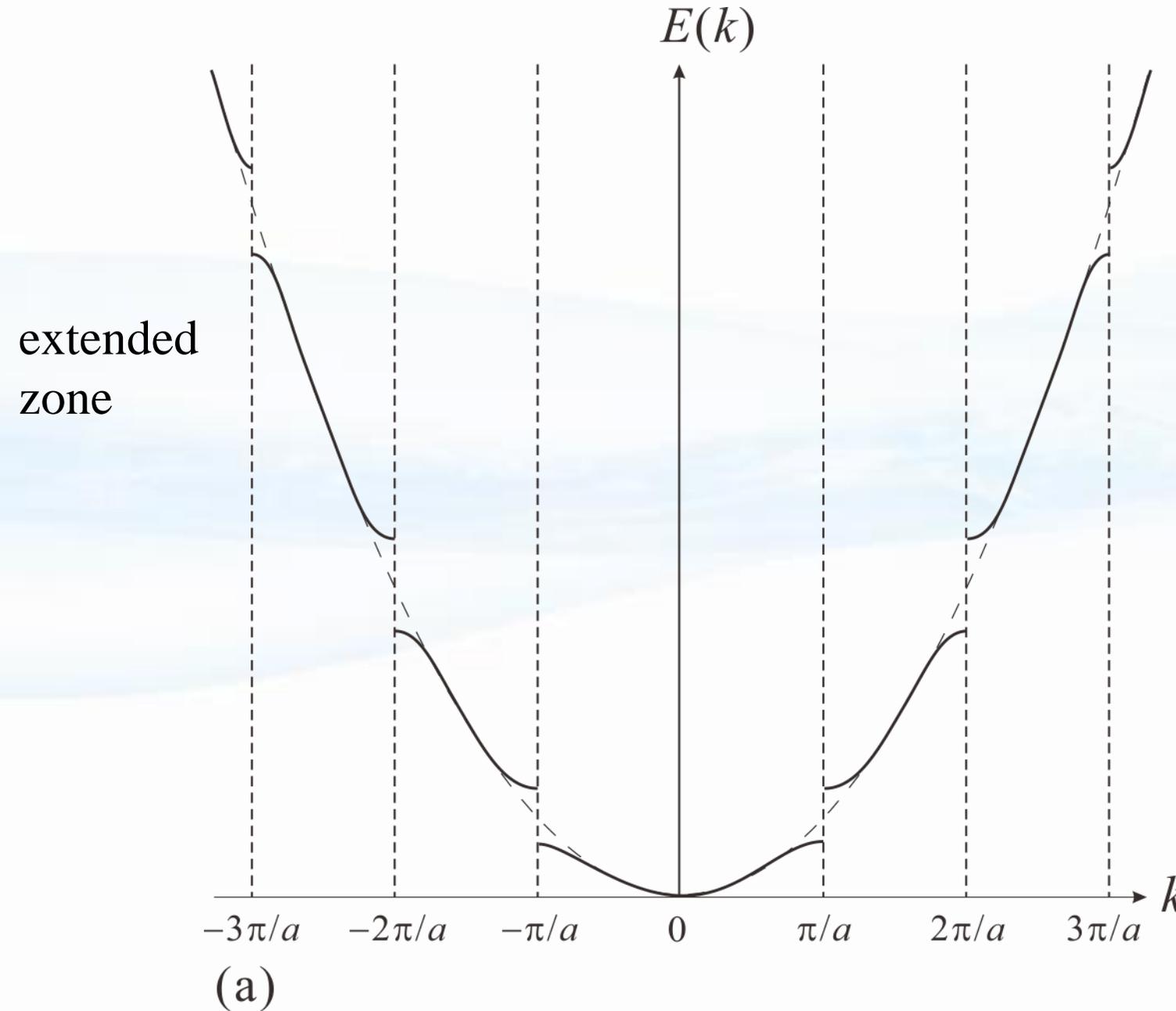
Points $k_w/2$ and $-k_w/2$ are equivalent

Shifts from these points can be renormalized into $u_{n\mathbf{k}}(\mathbf{r})$

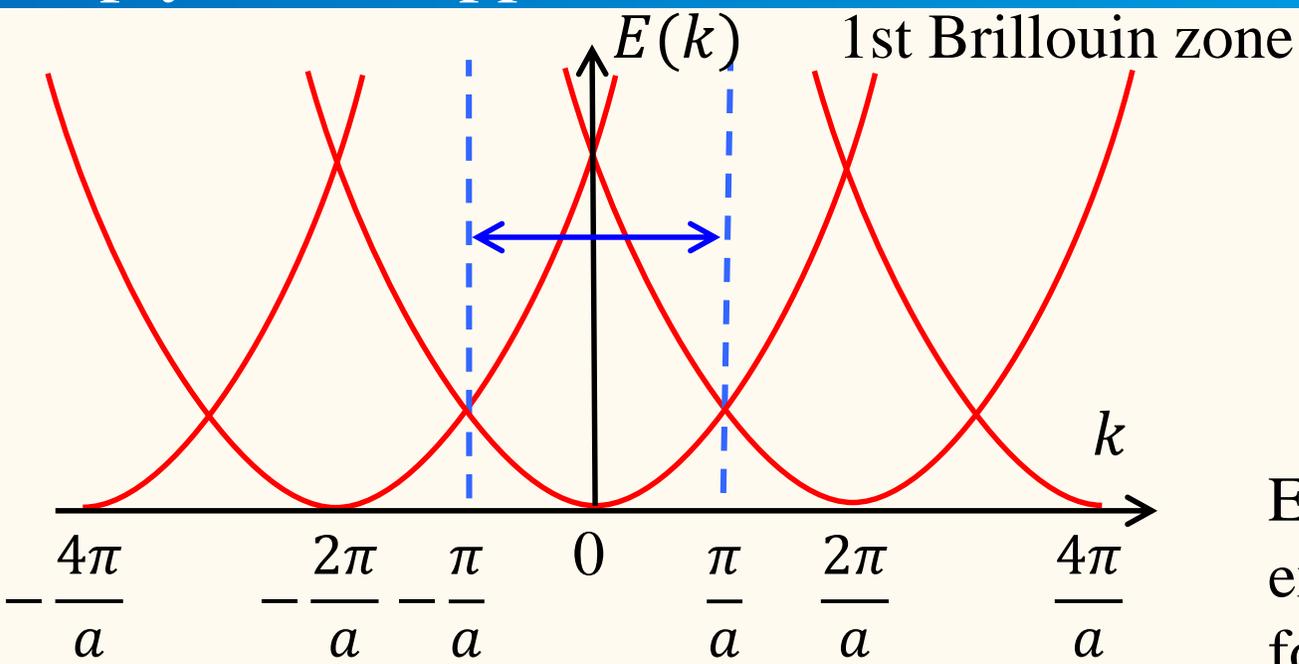
→

Reduced zone expression

Nearly free electron model (3) Reduced zone expression



Empty lattice approximation

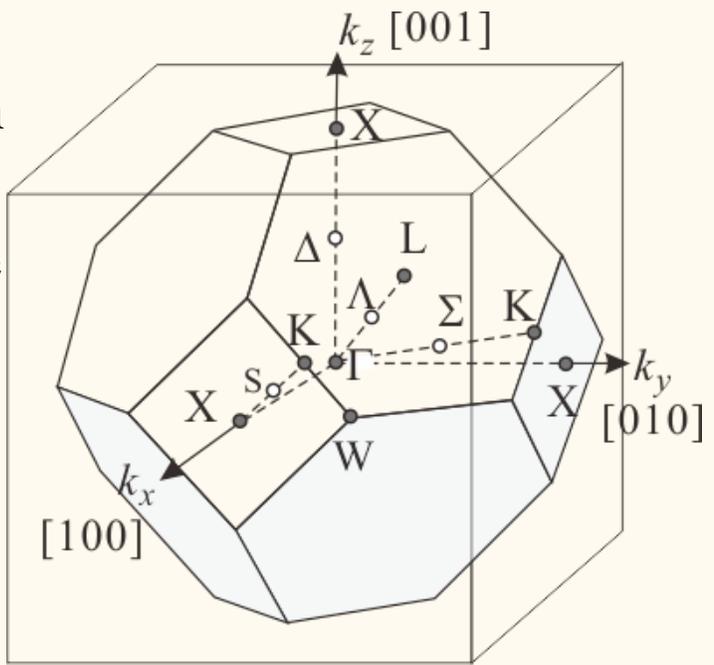


$$V_0 \rightarrow 0 \quad e^{ikx} = e^{i(k-k_w)x} e^{ik_w x}$$

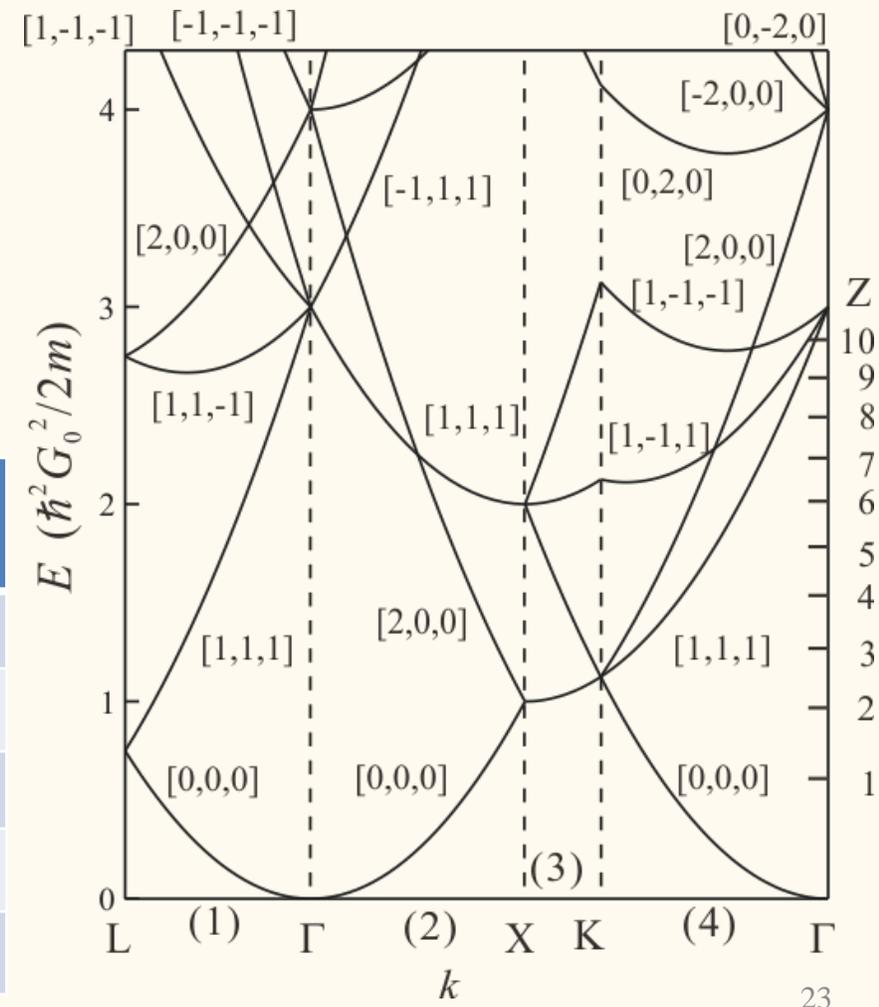
The free space has a lattice periodicity.

Empty lattice expression for fcc

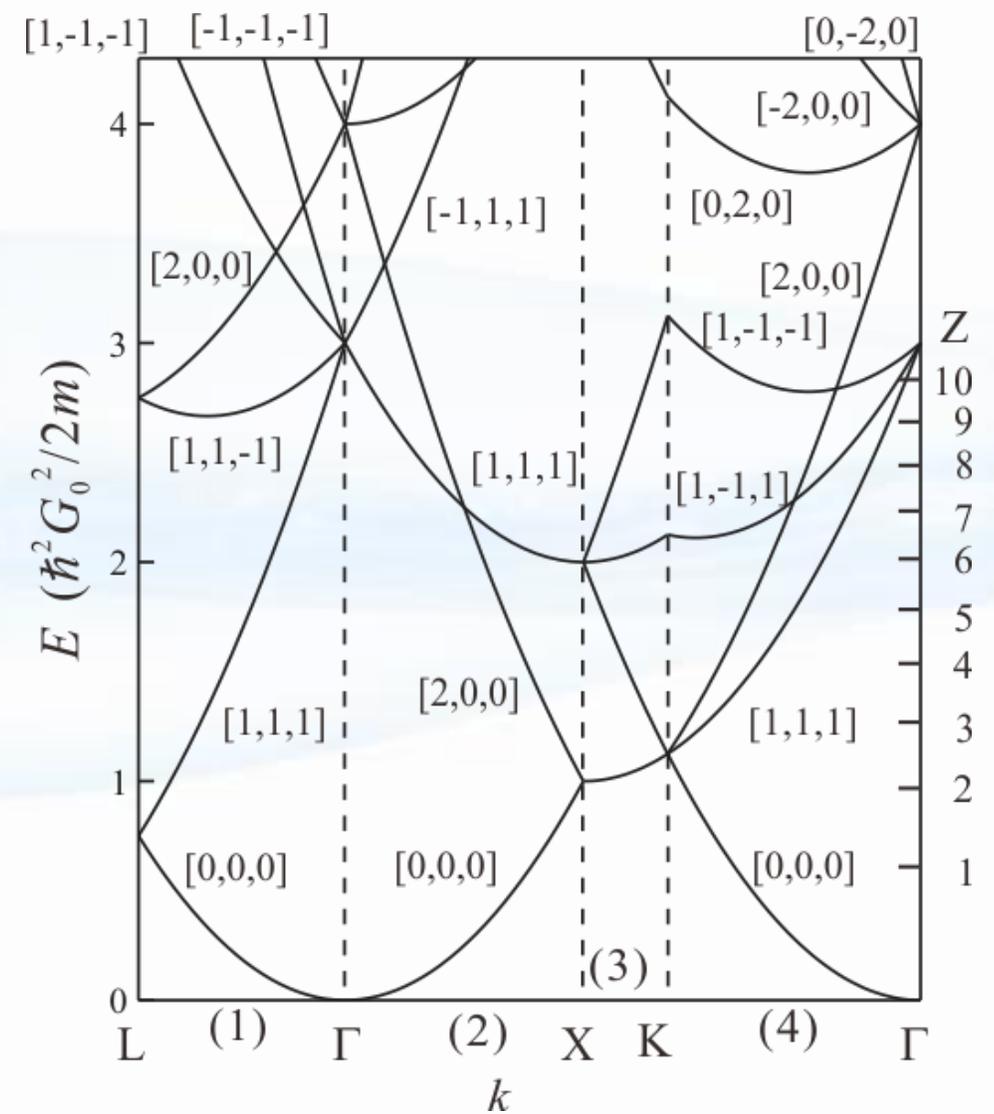
1st Brillouin zone of fcc lattice



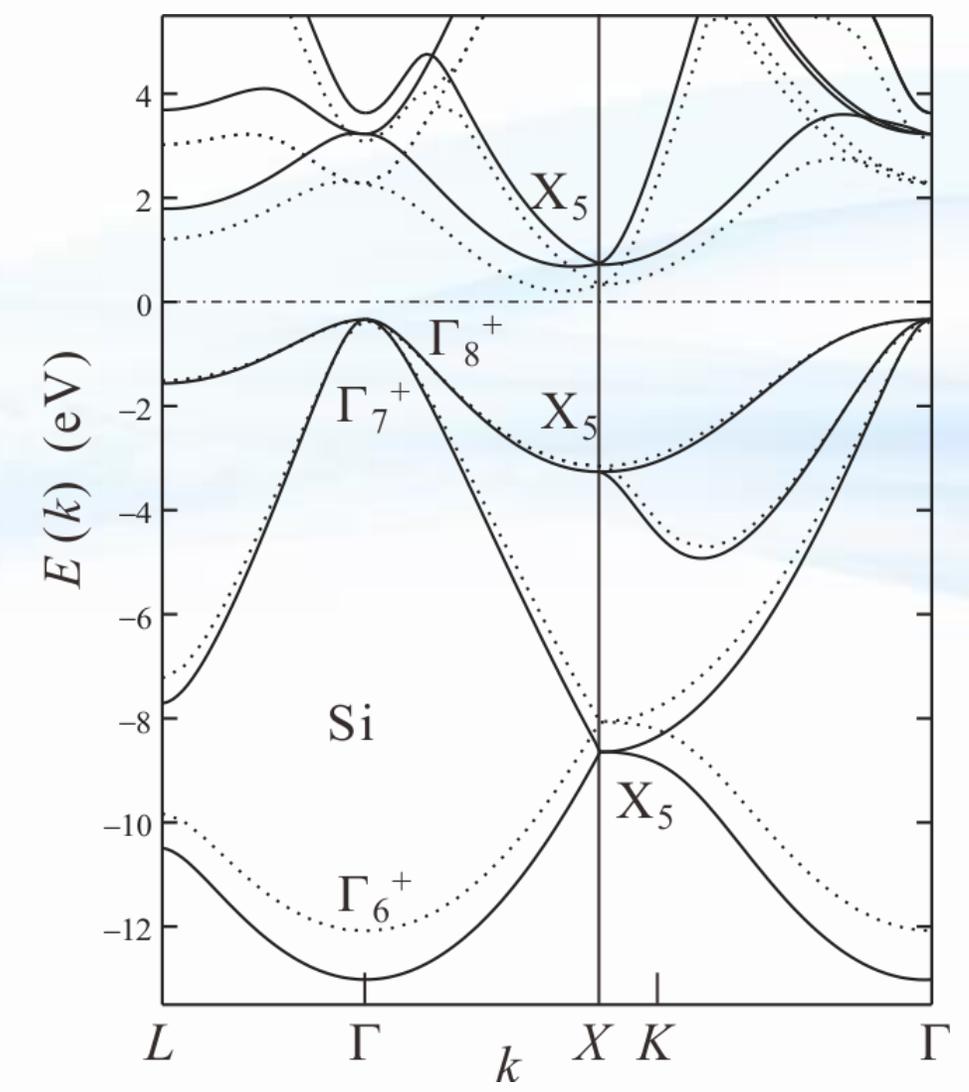
| distance | Points | number |
|-------------|-------------|--------|
| 0 | (0,0,0) | 1 |
| $\sqrt{3}$ | (1,1,1),... | 8 |
| 2 | (2,0,0),... | 6 |
| $\sqrt{8}$ | (2,0,2),... | 12 |
| $\sqrt{11}$ | (3,1,1),... | 24 |



Empty lattice approximation and more realistic band structure



Empty



Si pseudo potential calculation

Tight-binding approximation

Single atom on single unit cell

Single atom Hamiltonian: $\mathcal{H}_a = \hat{T} + u$

\hat{T} : kinetic energy, u : atomic potential

$$\mathcal{H}_a(R_i) = \hat{T} + u(r - R_i)$$

$$\mathcal{H}_a(R_i)\phi_n(r - R_i) = \epsilon_n\phi_n(r - R_i)$$

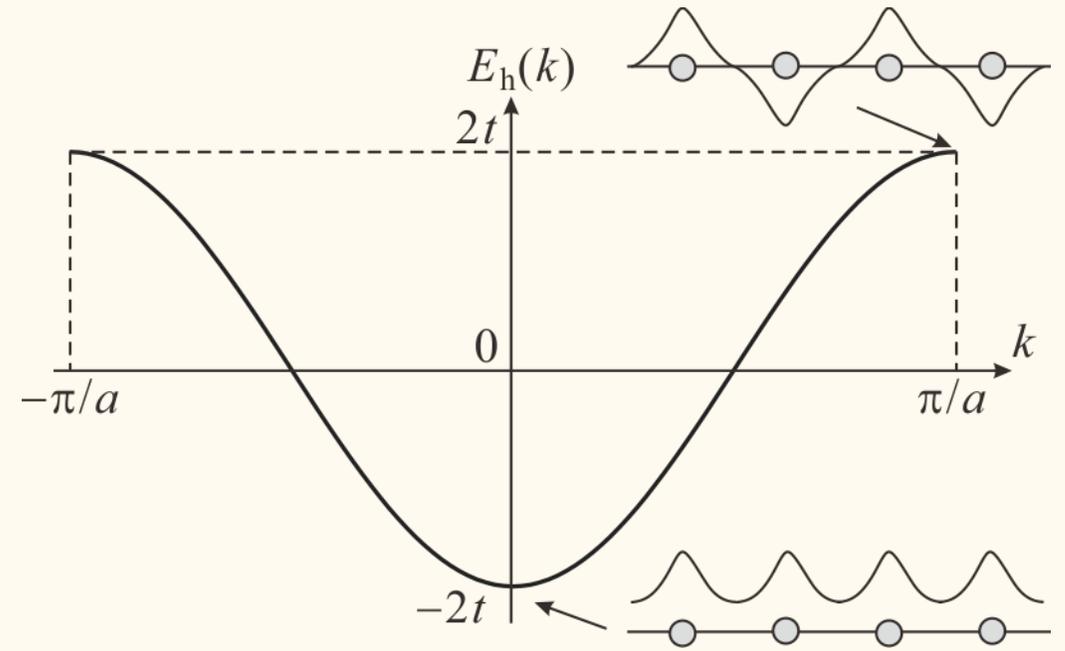
ϕ_n : eigenfunctions for $R_i = 0$

$$\begin{aligned}\psi_{nk}(r) &= \frac{1}{\sqrt{N}} \sum_i e^{ikR_i} \phi_n(r - R_i) \\ &= \frac{e^{ikr}}{\sqrt{N}} \left[\sum_i e^{-ik(r-R_i)} \phi_n(r - R_i) \right]\end{aligned}$$

Lattice periodic function

: Bloch form

$$\mathcal{H} = [\hat{T}_x + V(x)]\psi(x) = E\psi(x)$$



Tight binding approximation (2)

$$\begin{aligned}\langle \psi_{nk} | \mathcal{H} | \psi_{nk} \rangle &= N^{-1} \sum_{i,j} e^{ik(R_j - R_i)} \langle \phi_n(r - R_i) | [\hat{T}_r + V(r)] | \phi_n(r - R_j) \rangle \\ &= N^{-1} \sum_{i,j} e^{ik(R_j - R_i)} \\ &\quad \times \langle \phi_n(r - R_i) | [\hat{T}_r + u(r - R_i) + V(r) - u(r - R_i)] | \phi_n(r - R_j) \rangle \\ &= \epsilon_n + N^{-1} \sum_{i,j} e^{ik(R_j - R_i)} \langle \phi_n(r - R_i) | [V(r) - u(r - R_i)] | \phi_n(r - R_j) \rangle \\ &= \epsilon_n + \sum_j e^{ikR_j} \langle \phi_n(r) | [V(r) - u(r)] | \phi_n(r - R_j) \rangle.\end{aligned}$$

$$E_n(k) = \epsilon_n + \langle \phi_n(r) | v(r) | \phi_n(r) \rangle - \sum_{R_j \neq 0} e^{ikR_j} t_n(R_j)$$

$$\alpha_n \equiv -\langle \phi_n(r) | v(r) | \phi_n(r) \rangle \quad \text{Crystal field contribution}$$

$$t_n(R_j) \equiv -\langle \phi_n(r) | v(r) | \phi_n(r - R_j) \rangle \quad \text{Hopping integral}$$

Tight binding approximation (3)

t_n nearest neighbor only = t

$$\begin{aligned} E_n(k) &= \epsilon_n - \alpha_n - t(e^{ika} + e^{-ika}) \\ &= \epsilon_n - \alpha_n - 2t \cos ka \end{aligned}$$

Cosine band with the width of $4t$.

